

<b>FORM PTO-1449 (MODIFIED)</b>  LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT  (Use several sheets if necessary)	ATTY DOCKET NO.	SERIAL NO.
	67,200-377	Filed Herewith
	APPLICANT Fu-Liang Yang	
	FILING DATE Filed Herewith	GROUP Unknown

REFERENCE DESIGNATION U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUB CLASS	FILING DATE
DP	AA	5,023,671	Jun/1991	DiVincenzo et al			
DP	AB	5,119,151	Jun/1992	Onda			
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES/NO
	AK						
	AL						
	AM						
	AN						

OTHER ART (including Author, Title, Date, pertinent pages, etc.)

DP	AO	Sallagoity et al, "Analysis of Width Edge Effects in Advanced Isolation Schemes for Deep Submicron CMOS Technologies", IEEE Trans. on Electron Devices, 44(11), Nov. 1996, pp. 1900-05.
DP	AP	Matsuda et al, "Novel Corner Rounding Process for Shallow Trench Isolation Utilizing MSTs (Micro-Structure Transformation of silicon). IEEE IEDM98, pp. 137-40.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.